L Numbe	1		DB	Time stamp
	35138	atomiz\$6	USPAT	2002/07/09 06:16
2	2555	bst or bsto	USPAT	2002/07/09 06:16
3	60	atomiz\$6 and (bst or bsto)	USPAT	2002/07/09 06:16
4	115		USPAT	2002/07/09 06:16
5	40	1	USPAT	2002/07/09 06:16
6	3	(atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.	USPAT	
7	3	(("6143063") or ("5962085") or ("5456945")).PN.		2002/07/09 06:20
8	_	atomiz\$6 same (bst or bsto)	USPAT	2002/07/09 06:21
	16		USPAT	2002/07/09 06:21
9	16	(atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)	USPAT	2002/07/09 06:21
10	16	bsto)) and 427/126.3.ccls.)) not ((("6143063") or ("5962085") or ("5456945")).PN.)	USPAT	2002/07/09 06:53
11	110007	atomiz\$6 or mist\$4 or aerosol	USPAT	2002/07/09 08:48
12	172	(atomiz\$6 or mist\$4 or aerosol) and (bst or bsto)	USPAT	2002/07/09 06:53
13	85949	oxide near 2 (film or layer)	USPAT	2002/07/09 06:54
14	357	(oxide near 2 (film or layer)) same (atomiz \$6 or mist \$4 or	USPAT	
ŀ		aerosol)		2002/07/09 06:54
15	21	(bst or bsto) and ((oxide near2 (film or layer)) same (atomiz\$6 or mist\$4 or aerosol))	USPAT	2002/07/09 06:55
16	17	((bst or bsto) and ((oxide near2 (film or layer)) same (atomiz\$6 or mist\$4 or aerosol))) not ((atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.))	USPAT	2002/07/09 07:06
17	28718	(atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)	USPAT	2002/07/09 07:08
18	1609	((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)	USPAT	2002/07/09 07:09
19	191	(((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))	USPAT	2002/07/09 07:09
20	0	((((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and 427/	USPAT	2002/07/09 07:09
21	55	((((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and 427/\$.ccls.	USPAT	2002/07/09 07:31
22	10978	(oxide near2 (film or layer)) near2 metal	USPAT	2002/07/00 07 77
23		((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt	USPAT	2002/07/09 07:33 2002/07/09 07:35
24	93616	(((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)	USPAT	2002/07/09 07:36
25	527	(atomiz\$6 or mist\$4 or aerosol) same ((((oxide near2 (film	USPAT	2002/07/09 07:36
		or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))		
26	F00			
	508	(atomiz\$6 or mist\$4 or aerosol) near10 precursor	USPAT	2002/07/09 07:36
27	1965	((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor	USPAT	2002/07/09 07:36
28	119	((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and (((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor)	USPAT	2002/07/09 07:37
29	581	((atomiz\$6 or mist\$4 or aerosol) same (((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))) or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and ((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide)) near10	USPAT	2002/07/09 07:37
		precursor))		
30	2025	((427/81) or (427/126.3) or (427/226)).CCLS.	USPAT	2002/07/09 07:38

31	39	(((atomiz\$6 or mist\$4 or aerosol) same ((((oxide near2	USPAT	1 2002/07/00 07 70
	3,	(film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))) or (((atomiz\$6 or mist\$4 or aerosol)	USFAT	2002/07/09 07:38
		near 10 precursor) and (((((oxide near 2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))		
		near10 precursor))) and (((427/81) or (427/126.3) or (427/226)).CCLS.)		
32	36		USPAT	2002/07/09 07:38
		(film or layer)) near2 metal) or (bst or bsto) or sbt) or		
		(metal adj oxide))) or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and ((((oxide near2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))		
		near10 precursor))) and (((427/81) or (427/126.3) or		
		(427/226)).CCLS.)) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)		
33	30	(((())))	USPAT	2002/07/09 07:44
		(film or layer)) near2 metal) or (bst or bsto) or sbt) or		
		(metal adj oxide))) or (((atomiz\$6 or mist\$4 or aerosol)		
		near 10 precursor) and (((((oxide near 2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor))) and (((427/81) or (427/126.3) or		
		(427/226)).CCLS.)) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)) not (((((atomiz\$6 or mist\$4 or aerosol)		
		same (temperature or heat\$4 or degree\$5)) same (vacuum		
		or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or		
	_	layer)))) and 427/\$.ccls.)		
34	3	((((((atomiz\$6 or mist\$4 or aerosol) same ((((oxide near2	USPAT	2002/07/09 08:56
		(film or layer)) near2 metal) or (bst or bsto) or sbt) or		
		(metal adj oxide))) or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and ((((oxide near2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))		
		near 10 precursor))) and (((427/81) or (427/126.3) or		
		(427/226)).CCLS.)) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)) not (((((atomiz\$6 or mist\$4 or aerosol)		
		same (temperature or heat\$4 or degree\$5)) same (vacuum		
		or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and 427/\$.ccls.)) and (torr or mmhg)		
35	354	(atomiz\$6 or mist\$4 or aerosol) same (torr or mmhg)	USPAT	2002/07/09 07:46
36	65	((((oxide near2 (film or layer)) near2 metal) or (bst or bsto)	USPAT	2002/07/09 07:46
		or sbt) or (metal adj oxide)) and ((atomiz\$6 or mist\$4 or	45.71	2002/0//0/ 0/.40
		aerosol) same (torr or mmhg))		
37	2968	((((oxide near2 (film or layer)) near2 metal) or (bst or bsto)	USPAT	2002/07/09 07:46
70	0.4	or sbt) or (metal adj oxide)) and ((bst or bsto) or sbt)		
38	24	((atomiz\$6 or mist\$4 or aerosol) same (torr or mmhg)) and ((bst or bsto) or sbt)	USPAT	2002/07/09 08:08
39	73767	(heat\$4 or temperature) near3 (substrate or wafer)	USPAT	2002/07/00 00 10
40	521	((heat\$4 or temperature) near3 (substrate or wafer)) same	USPAT	2002/07/09 08:10 2002/07/09 08:10
		(atomiz\$6 or mist\$4 or aerosol)	4317(1	2002/0//09 08:10
41	165	(((heat\$4 or temperature) near3 (substrate or wafer)) same	USPAT	2002/07/09 08:10
		(atomiz\$6 or mist\$4 or aerosol)) and ((((oxide near2 (film		
		or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj		
42	167	oxide)) (((heat\$4 or temperature) mean7 (substrate or unifor))	LICDAT	2222 (27 (22 22)
72	107	(((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure	USPAT	2002/07/09 08:11
!		or torr or mmhg)		
43	83	((((heat\$4 or temperature) near3 (substrate or wafer)) same	USPAT	2002/07/09 08:11
		(atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure		
		or torr or mmhg)) and ((((oxide near2 (film or layer)) near2		
		metal) or (bst or bsto) or sbt) or (metal adj oxide))		

44	67	((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and (((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or	USPAT	2002/07/09 08:11
		mmhg)) and ((bst or bsto) or sbt))		
45	100	((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not (((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and ((((oxide	USPAT	2002/07/09 08:11
		near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))) not (((atomiz\$6 or mist\$4 or aerosol)		
46	67	(atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not ((((heat\$4 or temperature) near3	USPAT	2002/07/09 08:12
		(substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not ((((((heat\$4 or temperature) near3 (substrate or wafer))		
		same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and ((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj		
		oxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or		
47	62	mmhg)) and ((bst or bsto) or sbt)))) (((((heat\$4 or temperature) near3 (substrate or wafer))	USPAT	2002/07/09 08:13
''	02	same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or	USFAT	2002/0//09 08:13
		pressure or torr or mmhg)) not (((((heat\$4 or temperature)		
		near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or		
		aerosol)) same (vacuum or pressure or torr or mmhg)) not ((((((heat\$4 or temperature) near3 (substrate or wafer))		
		same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or		
		pressure or torr or mmhg)) and ((((oxide near2 (film or		·
		layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj		
		oxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or mmhg)) and ((bst or bsto) or sbt))))) not (((((atomiz\$6 or		
		mist\$4 or aerosol) same ((((oxide near2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)))		
		or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and		
		(((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor))) and		
		(((427/81) or (427/126.3) or (427/226)).CCLS.)) not		
		((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not		
		((((((atomiz\$6 or mist\$4 or aerosol) same (temperature or		
		heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or		
		bsto) or sbt or (oxide near2 (film or layer)))) and 427/\$.ccls.))		

48	62	((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not (((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not ((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and (((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or mmhg)) and ((bst or bsto) or sbt)))) not (((((atomiz\$6 or mist\$4 or aerosol) same ((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))) or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and (((((oxide near2 (film or layer)) near10 precursor))) and (((427/81) or (427/126.3) or (427/226)).CCLS.)) not (((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not (((((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and 427/\$.ccls.))) not (((atomiz\$6 and (bst or bsto)) and 427/\$.ccls.))) not ((atomiz\$6 and (bst or bsto)) and 427/\$.ccls.))) not ((atomiz\$6 and (bst or bsto)) and 427/\$.ccls.)))	USPAT	2002/07/09 08:13
49	49	(((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not (((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not (((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and (((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or mmhg)) and ((bst or bsto) or sbt)))) not (((((atomiz\$6 or mist\$4 or aerosol) same (torr or mist\$4 or aerosol) same (((oxide near2 (film or layer))) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide))) or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and ((((oxide near2 (film or layer))) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor))) and ((((27/81) or (427/126.3) or (427/226)).CCLS.)) not (((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not ((((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and 427/\$.ccls.))) not (((atomiz\$6 and (bst or bsto))) and 427/126.3.ccls.)) not (((atomiz\$6 and (bst or bsto))) and 427/126.3.ccls.)) not (((atomiz\$6 and (bst or bsto))) and 427/126.3.ccls.)) not (((atomiz\$6 and (bst or bsto))) not (((atomiz\$6 and (bst or bsto)))) not (((atomiz\$6 and (bst or bsto)))))	USPAT	2002/07/09 08:13

50	47	((((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not (((((heat\$4 or temperature)	USPAT	2002/07/09 08:13
		near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) not		
		((((((heat\$4 or temperature) near3 (substrate or wafer))		
		same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or pressure or torr or mmhg)) and ((((oxide near2 (film or		
		layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj		
		oxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or		
		mmhg)) and ((bst or bsto) or sbt))))) not (((((atomiz\$6 or mist\$4 or aerosol) same ((((oxide near2 (film or layer))		
		near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)))		
		or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and		
		(((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)) near10 precursor))) and		
		(((427/81) or (427/126.3) or (427/226)).CCLS.)) not		
		((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not		
		(((((atomiz\$6 or mist\$4 or aerosol) same (temperature or heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or		
		bsto) or sbt or (oxide near2 (film or layer)))) and		
		427/\$.ccls.))) not ((atomiz\$6 and (bst or bsto)) and		·
		427/126.3.ccls.)) not (((atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not		
		((("6143063") or ("5962085") or ("5456945")).PN.)))		
		not (((bst or bsto) and ((oxide near2 (film or layer)) same		
		(atomiz\$6 or mist\$4 or aerosol))) not ((atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)))		
51	47	((((((((heat\$4 or temperature) near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or	USPAT	2002/07/09 08:33
		pressure or torr or mmhg)) not (((((heat\$4 or temperature)		
		near3 (substrate or wafer)) same (atomiz\$6 or mist\$4 or		
		aerosol)) same (vacuum or pressure or torr or mmhg)) not ((((((heat\$4 or temperature) near3 (substrate or wafer))		
		same (atomiz\$6 or mist\$4 or aerosol)) same (vacuum or		
		pressure or torr or mmhg)) and ((((oxide near2 (film or		
		layer)) near2 metal) or (bst or bsto) or sbt) or (metal adjoxide))) not (((atomiz\$6 or mist\$4 or aerosol) same (torr or		
		mmhg)) and ((bst or bsto) or sbt))))) not ((((((atomiz\$6 or		
		mist\$4 or aerosol) same ((((oxide near2 (film or layer)) near2 metal) or (bst or bsto) or sbt) or (metal adj oxide)))		
		or (((atomiz\$6 or mist\$4 or aerosol) near10 precursor) and		
		(((((oxide near2 (film or layer)) near2 metal) or (bst or		
		bsto) or sbt) or (metal adj oxide)) near10 precursor))) and (((427/81) or (427/126.3) or (427/226)).CCLS.)) not		
		((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not		
		(((((atomiz\$6 or mist\$4 or aerosol) same (temperature or		
		heat\$4 or degree\$5)) same (vacuum or torr)) and ((bst or bsto) or sbt or (oxide near2 (film or layer)))) and		
		427/\$.ccls.))) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)) not (((atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and 427/126.3.ccls.)) not		
		((("6143063") or ("5962085") or ("5456945")).PN.)))		
		not (((bst or bsto) and ((oxide near2 (film or layer)) same		
		(atomiz\$6 or mist\$4 or aerosol))) not ((atomiz\$6 same (bst or bsto)) not ((atomiz\$6 and (bst or bsto)) and		
		427/126.3.ccls.)))) not (((atomiz\$6 or mist\$4 or aerosol)		
F 2	00004	same (torr or mmhg)) and ((bst or bsto) or sbt))		
52 53	92286 266	boiling adj point (boiling adj point) near4 torr	USPAT USPAT	2002/07/09 08:34 2002/07/09 08:34
		/9 mai / rous / rous / rous	431 A I	2002/07/07 00:34

54	105012	atomiz\$6 or atomis\$6 or mist\$4 or aerosol	EPO; JPO;	12002/07/00 00 40
		The state of the s	DERWENT;	2002/07/09 08:49
			IBM TDB	
55	326	(atomiz\$6 or atomis\$6 or mist\$4 or aerosol) same (bst or	EPO; JPO;	2002/07/09 08:50
		bsto or sbt or (metal adj oxide) or (barium adj strontium) or	DERWENT;	2002/07/09 08:50
		(strontium adj barium))	IBM TDB	
56	10		EPO; JPO;	2002/07/00 00 57
		bsto or sbt or (metal adj oxide) or (barium adj strontium) or	DERWENT;	2002/07/09 08:53
		(strontium adj barium))) same (vacuum or torr or mmhg)	IBM TDB	
57	217	(atomiz\$6 or atomis\$6 or mist\$4 or aerosol) same (oxide	EPO; JPO;	2002/07/00 00 57
		adj (film or layer))	DERWENT;	2002/07/09 08:53
		adj (min or layer))	IBM TDB	
58	15	((atomiz\$6 or atomis\$6 or mist\$4 or aerosol) same (oxide		0000 (07 (00 00 74
		adj (film or layer))) same (vacuum or torr or mmhg)	EPO; JPO;	2002/07/09 08:54
		day (min or layer)// same (vacuum or torr or mining)	DERWENT;	
59	14	(((atomiz\$6 or atomis\$6 or mist\$4 or aerosol) same (oxide	IBM_TDB	2000/07/00 00 7
37		adj (film or layer))) same (vacuum or torr or mmhg)) not	EPO; JPO;	2002/07/09 08:54
		(((atomiz\$6 or atomis\$6 or mist\$4 or aerosol) same (bst or	DERWENT;	
		bsto or sbt or (metal adj oxide) or (barium adj strontium) or	IBM_TDB	
		(strontium adj barium))) same (vacuum or torr or mmhg))		
60	0	(atomiz\$6 or mist\$4 or aerosol) same (dpm same	LICDAT	
		acetylaceton\$4)	USPAT	2002/07/09 08:56
61	3074	dpm or dipivalometan45	USPAT	2000/07/00 00 55
62	13714	acetylaceton\$5	USPAT	2002/07/09 08:57
63	3074	dpm or dipivalomethan45	USPAT	2002/07/09 08:57
64	3074	dpm or dipivaloymethan 45		2002/07/09 08:57
65	3074	dpm or dipivaloylmethan45	USPAT	2002/07/09 08:58
66	3210	dpm or dipivaloylmethan\$5	USPAT USPAT	2002/07/09 09:00
67	113	acetylaceton\$5 same (dpm or dipivaloylmethan\$5)	USPAT	2002/07/09 09:03
68	6	(atomiz\$6 or mist\$4 or aerosol) and (acetylaceton\$5 same		2002/07/09 09:03
		(dpm or dipivaloylmethan\$5))	USPAT	2002/07/09 09:05
69	o	(acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) same	LICDAT	2000/27/22 22 27
• .		bst (april of dipivaloyimethan \$5)) same	USPAT	2002/07/09 09:05
70	0	(acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) same	LICDAT	2000/27/20 22 22
. •		bst	USPAT	2002/07/09 09:05
72	0	((acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) same	LICDAT	
		precursor) and bst	USPAT	2002/07/09 09:05
73	0	((acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) same	LICD A T	
, ,		precursor) and sbt	USPAT	2002/07/09 09:06
71	13	(acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) same	1100 4 =	
, ,	13	precursor (dpm or dipivaloyimethan\$5)) same	USPAT	2002/07/09 09:06
74	1 1	(acetylaceton\$5 same (dpm or dipivaloylmethan\$5)) and bst	1150.7	
		(acceptaceton \$3 same (apin or dipivaloyimethan \$5)) and bst	USPAT	2002/07/09 09:06